AMENDMENT TRANSMITTAL LETTER (Small Entity) Applicant(s): Mehr						Docket No. <sup>1</sup> 010456		
		g Date ay 2001	\\		) ·		Group Art Unit	
10 May 2001 Easthom, Karl D  Invention: Integrated Polycrystalline Silicon Resistor with Carbon or Germanium  TO THE ASSISTANT COMMISSIONER FOR PATENTS:  Transmitted herewith is an amendment in the above-identified application.								
Transmitted herewith is an amendment in the above-identified application.  Small Entity status of this application has been established under 37 CFR 1.27 by a verified statement previously submitted.  A verified statement to establish Small Entity status under 37 FR 1.27 is enclosed.								
The fee has been calculated and is transmitted as shown below.								
CLAIMS AS AMENDED								
	CLAIMS REMAINING	HIGHEST #	NUMBE	R EXTRA	RATE		ADDITIONAL	
	AFTER AMENDMENT	PREV. PAID FOR	R CLAIMS	PRESENT			FEE	
TOTAL CLAIMS	11 -	20 =		0		9.00	\$0.00	
INDEP. CLAIMS	2 -	3 =		0	x \$	42.00	\$0.00	
Multiple Dependent Claims (check if applicable)							\$0.00	
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT \$0.00								
No additional fee is required for amendment.  Please charge Deposit Account No. in the amount of A duplicate copy of this sheet is enclosed.  A check in the amount of to cover the filing fee is enclosed.  The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No.  A duplicate copy of this sheet is enclosed.  Any additional filing fees required under 37 C.F.R. 1.16.  Any patent application processing fees under 37 CFR 1.17.								
Dated: 17 September 2002								
Karl Hormann Registration No.:	<b>o</b>			df7 September first class ma Assistant Co 20231.	r 2002 iil under 3 ommission	with	and fee is being deposited the U.S. Postal Service as 1.8 and is addressed to the ratents, Washington, D.C.	

CC:

Karl Hormann

Typed or Printed Name of Person Mailing Correspondence



## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

Application No.: 09/807,947

Filed: 10 May 2001 By: Mehr, Wolfgang

For: Integrated Polycrystalline Silicon Resistor

with Carbon or Germanium

Examiner: Easthom, Karla

Group Art Unit: 2832

86 Sparks Street Cambridge MA 02138-2216 17 September 2002

Hon. Assistant Commissioner for Patents Washington DC 20231

## **Amendment**

Sir:

This is in response to the Official Action dated 17 May 2002. A petition to extend the period for response by one (1) months has been filed under separate cover.

Please amend the application as follows:

In the Claims:

Cancel claims 1 and 2 and substitute the following new claims:



3. (New) An integrated high-ohmic polycrystalline silicon resistor, comprising:

a substrate;

a dielectric substance;